



PATENT APPLICATION  
Do. No. 5484-48

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: **Byung-Sup SHIM et al.**

Serial No. 09/305,240

Examiner: O. Nadav

Filed: May 4, 1999

Group Art Unit: 2811

For: **OPEN DRAIN INPUT/OUTPUT STRUCTURE AND MANUFACTURING  
METHOD THEREOF IN SEMICONDUCTOR DEVICE**

Date: July 17, 2000

Box Non-Fee Amendment  
Commissioner of Patents and Trademarks,  
Washington, D.C. 20231

6/a  
FJONES  
7-27-00

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**AMENDMENT & RESPONSE TO OFFICE ACTION**

Responsive to the Office Action, dated April 17, 2000, please amend the application as follows.

**IN THE SPECIFICATION**

In page 1, at the beginning of the specification, immediately after the title, please add:

**CROSS REFERENCE TO RELATED APPLICATIONS**

This application claims priority from Korean Priority Document No. 1998-15975, filed on May 4, 1998 with the Korean Industrial Property Office, which document is hereby incorporated by reference.

In page 2, line 8, please insert - -with- - between "in series" and "each other".